AMENDMENT UNDER 37 C.F.R. § 1.111 Attorney Docket No.: Q90606

Application No.: 10/550,897

AMENDMENTS TO THE SPECIFICATION

Please replace the second full paragraph at page 32 of the specification with the following

amended paragraph:

Fig. 4 sows-shows the composition profile of silicon, oxygen and carbon in the direction

of depth of the film relying upon the method of analyzing the composition in the vapor deposited

film that is obtained. In the composition profile of Fig. 4, the sum of concentrations of silicon

and oxygen is shown in Fig. 5 as Si + O. Further, the bonding energy of silicon in Fig. 5 is

shown in Fig. 6.

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